



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Hiroshi SERA et al.

Group Art Unit: 1756

Application No.: 10/630,861

Examiner: C. SULLIVAN

Filed: July 31, 2003

Docket No.: 116741

For: METHOD OF MANUFACTURING RESIN INSULATING LAYER, SUBSTRATE
FOR ELECTRIC OPTICAL APPARATUS, METHOD OF MANUFACTURING
ELECTRIC OPTICAL APPARATUS, AND ELECTRIC OPTICAL APPARATUS

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

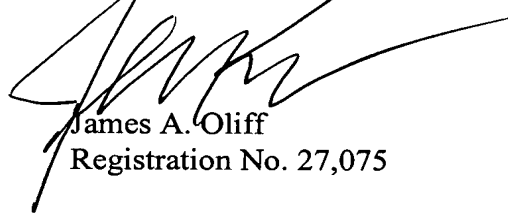
Sir:

In reply to the May 25, 2007 Restriction Requirement, Applicants provisionally elect
Group I, claims 1-4 and 8, with traverse.

It is also respectfully submitted that the subject matter of all claims is sufficiently
related that a thorough search for the subject matter of any one Group of claims would
encompass a search for the subject matter of the remaining claims. Thus, it is respectfully
submitted that the search and examination of the entire application could be made without
serious burden. See MPEP §803 in which it is stated that "if the search and examination of an
entire application can be made without serious burden, the examiner must examine it on the
merits, even though it includes claims to independent or distinct inventions" (emphasis
added). It is respectfully submitted that this policy should apply in the present application in
order to avoid unnecessary delay and expense to Applicants and duplicative examination by
the Patent Office.

Thus, withdrawal of the Restriction Requirement is respectfully requested.

Respectfully submitted,



James A. Oliff
Registration No. 27,075

John S. Kern
Registration No. 42,719

JAO:JSK/dxc

Date: July 9, 2007

OLIFF & BERRIDGE, PLC
P.O. Box 19928
Alexandria, Virginia 22320
Telephone: (703) 836-6400

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